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SPRING COLLEGE ON AMORPHOUS SOLIDS
AND THE LIQUID STATE

14 April - 18 June 1982

ELECTRONIC TRANSPORT IN NON-CRYSTALLINE SEMICONDUCTORS
(Part I)

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These are preliminary lecture notes, intended only for distribution to participants.
Missing or extra copies are available from Room 230.

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Model

Concepts

- Electronic States
- Localization
- Mobility Edge
- Random Phase
- Hopping
- Percolation

Predictions

- optical absorption
- luminescence
- recombination
- drift of carriers + trapping ✓
- dc, ac conductivity ✓
- thermopower ✓
- Hall effect ✓
-
-

Measurements

- ✓ Density of states $N(E)$
 - field effect
 - C-V
 - DLTS
- ✓ Drift mobility
 - transient decay
 - xerographic
 -
- ✓ μ_0
- Luminescence
- ✓ photoconductivity, rise + decay
- paramagnetic resonance

Discoveries

- ✓ photostructural changes
- ✓ photo-creation of defects
- ✓ field-enhanced doping
- anomalous C_v , κ , R
- characteristic differences - material classes

③

Reality

compositional } heterogeneities ✓
structural }

Surfaces and interfaces ✓

Dependence of properties on
preparation conditions

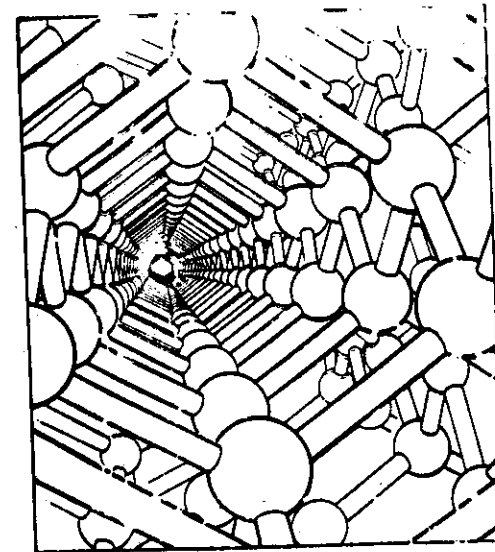


Fig. 9. Model of the diamond lattice (after Pauling and Hayward 1964).

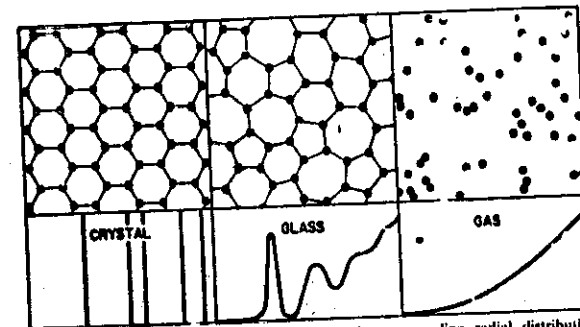
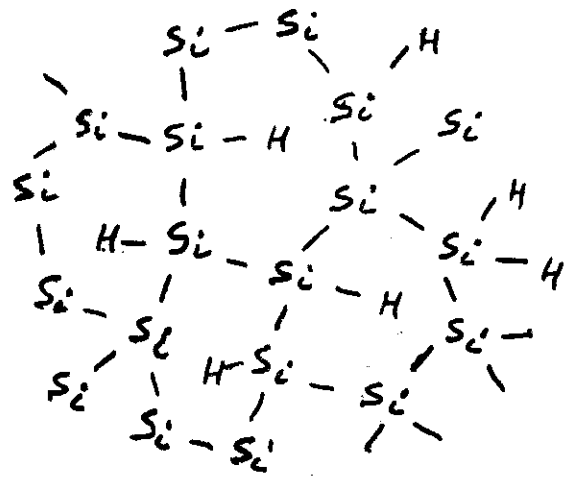
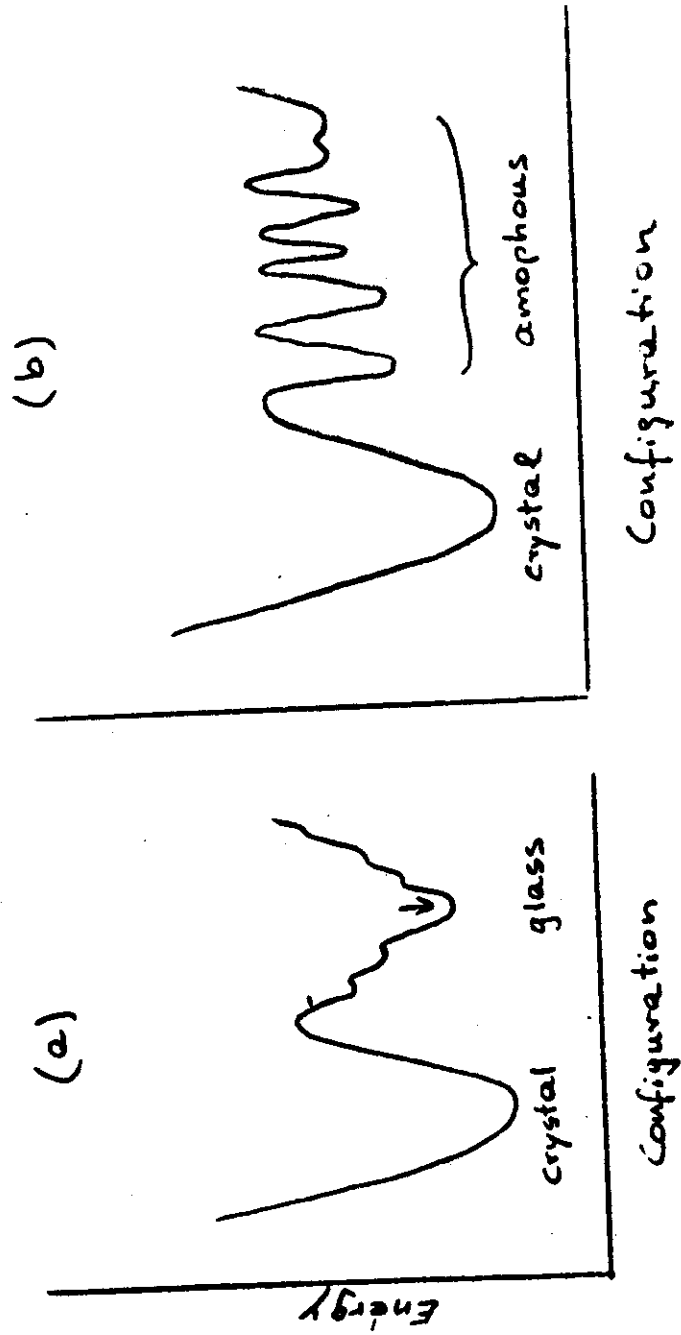


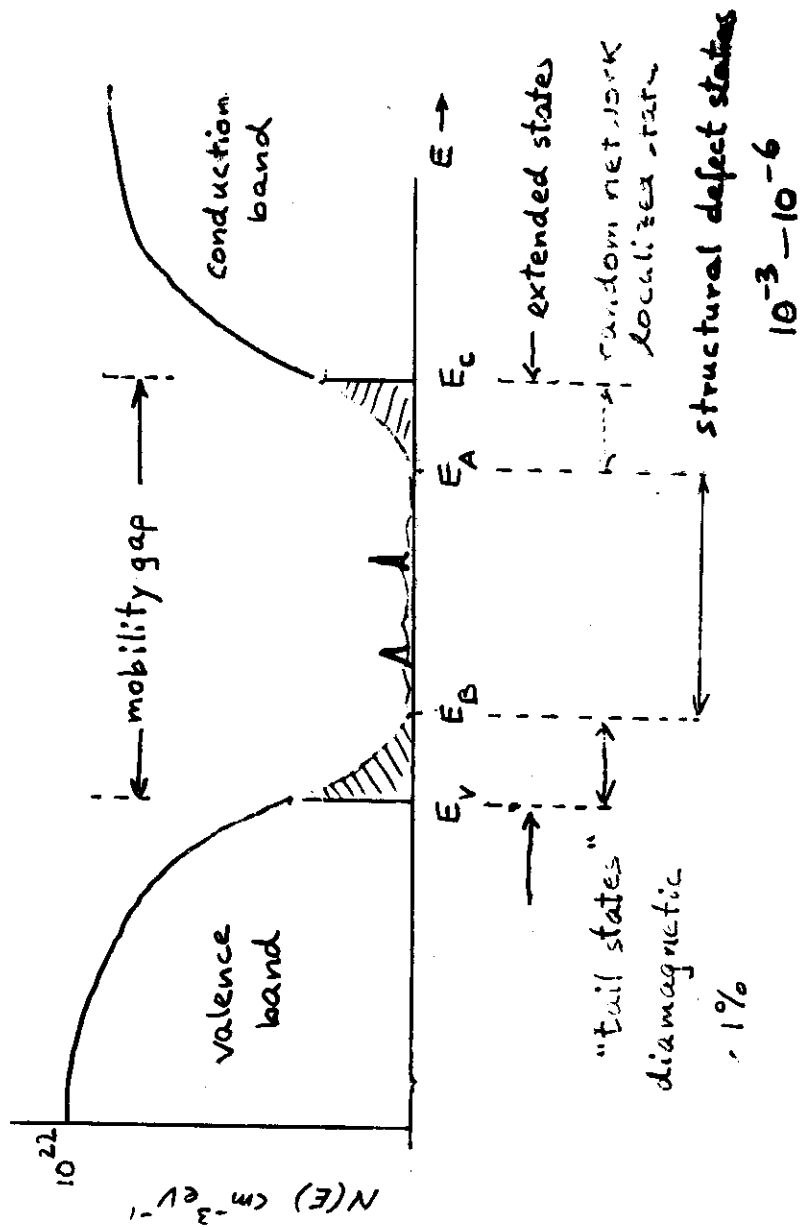
Fig. 1. Sketches of the atomic arrangements, and corresponding radial distributions, representative of crystalline solids, amorphous solids, and gases.



⑤

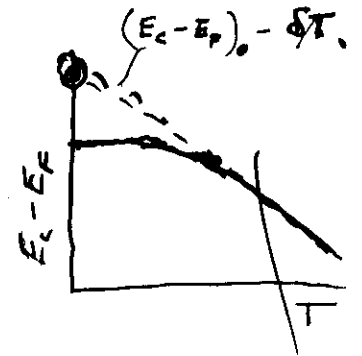


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N

$$\begin{aligned} \sigma &= \sigma_{\min} e^{-\frac{(E_C - E_F)}{kT}} \\ &= \sigma_{\min} e^{\frac{\delta/2}{kT}} e^{-\frac{(E_C - E_F)_0}{kT}} \\ &= \sigma_{\min} e^{-\frac{\Delta E}{kT}} \end{aligned}$$



$$\sigma_{\min} = 0.06 \left(\frac{6}{2}\right)^2 \frac{t_c}{d_c}$$

$$N(E_C) \sim 10^{21} \text{ eV}^{-1} \text{ cm}^{-3}$$

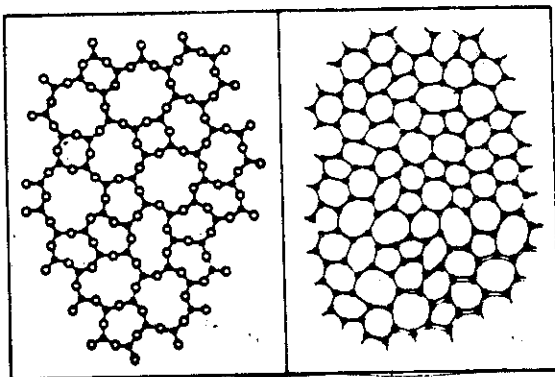
$$N_C = N(E_C) kT \sim 2.5 \times 10^{19} \text{ cm}^{-3}$$

$$d_c = \left(\frac{3}{4\pi}\right)^{1/3} \frac{1}{N_C^{1/3}} \sim 20 \text{ \AA}$$

$$\therefore \left. \begin{aligned} \sigma_{\min} &\approx 200 \text{ ohm}^{-1} \text{ cm}^{-1} \\ \sigma_{\min} &= e N_C \mu_c \end{aligned} \right\} \mu_c \sim 40 \text{ cm}^2/\text{Vs}$$

$$\mu_c = \frac{e}{kT} D = \frac{1}{6} \frac{e}{kT} d_c^2 v_{el} \sim 5 \text{ cm}^2/\text{Vs}$$

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Conduction

$$\sigma = e N_c \mu_c e^{-\frac{E_c - E_F}{kT}}$$

$$\begin{aligned} \mu_c &= \frac{1}{6} \frac{e}{\hbar} d^2 v_{el} \approx 4 \text{ cm}^2/\text{Vs} \\ N_c &= N(E_c) kT \approx 2.5 \times 10^{19} \text{ cm}^{-3} \\ e &= 1.6 \times 10^{-19} \text{ C} \end{aligned}$$

$$\sigma = 16 e^{-\frac{(E_c - E_F)}{kT}}$$

$$= 16 e^{\delta/\hbar} e^{-\frac{(E_{c0} - E_F)}{kT}}$$

$$e^{\delta/\hbar} = 30 \quad \text{with } \delta = \frac{1}{2} \gamma = 2.3 \times 10^{-4} \text{ eV/K}$$

$$\sigma = 500 e^{-E_a/kT}$$

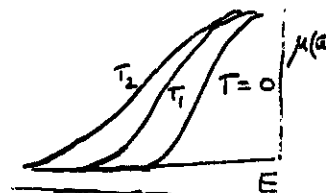
σ_0

$$S = \frac{k}{e} \left(\frac{E_a}{kT} - \frac{\delta}{k} + A \right)$$

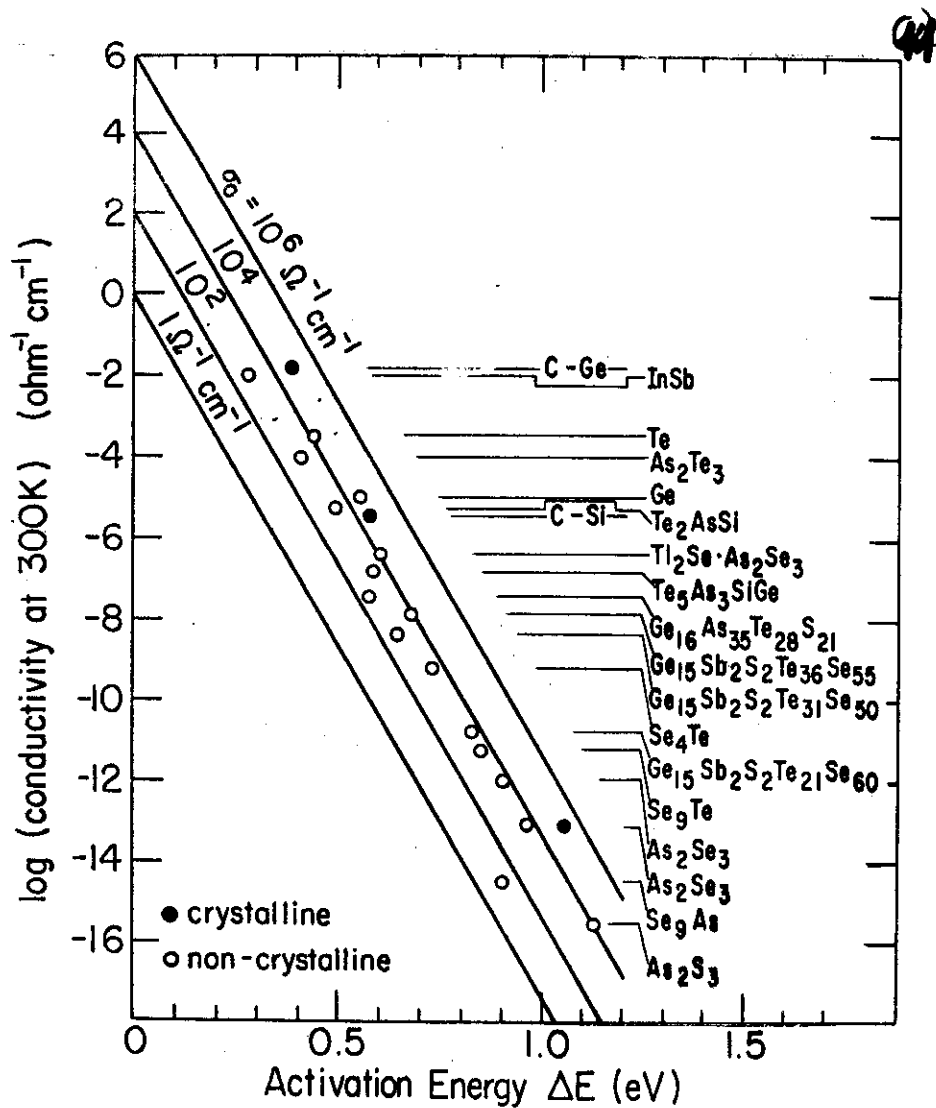
$$1. E_c(T) = E_{c0} - \delta_c T$$

$$\delta_c = 5 \times 10^{-4} \text{ eV/K}$$

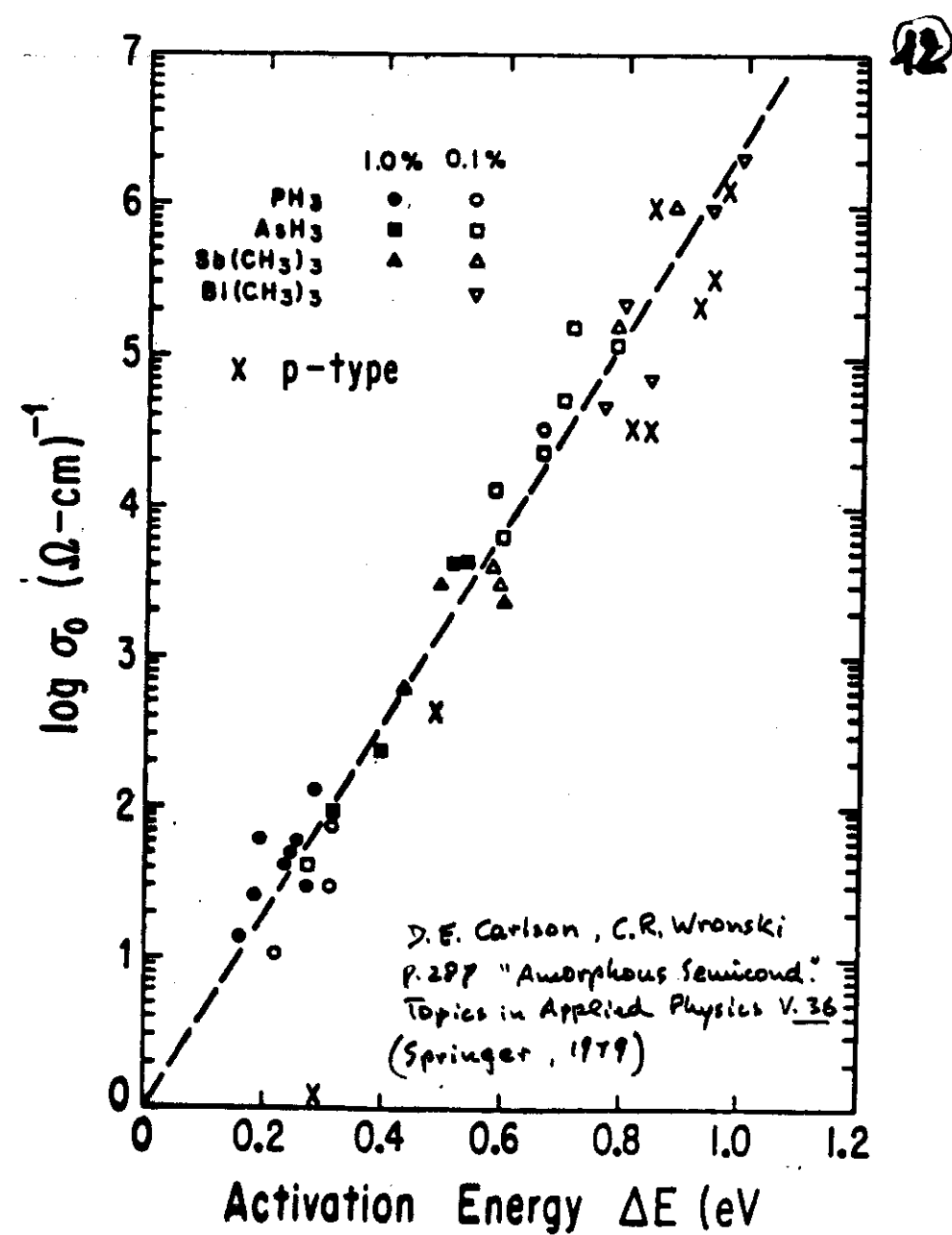
2. $E_F(T)$ moves away from E_c or E_v and decreases σ_c



3. Heterogeneities, potential barriers

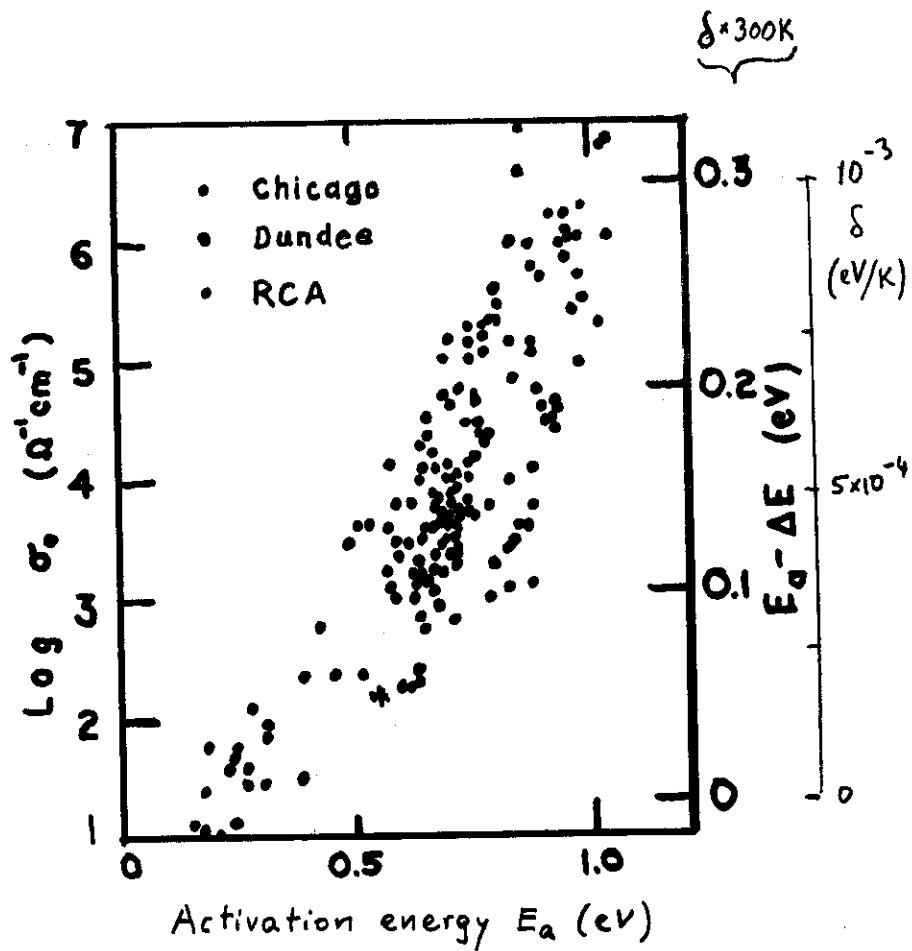


From: H. Fölltsche "Amorphous & Liquid Semicond." edited by J. Tauc, Academic Press



(13)

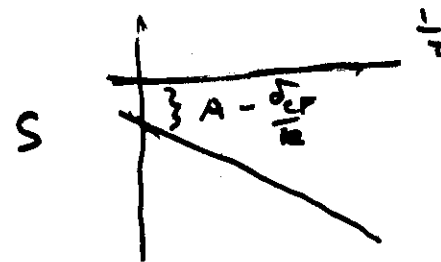
(14)



$$S = -\frac{k}{e} \left[\left(\frac{E_c - E_F}{kT} \right)_0 + A_c - \frac{\delta_{CF}}{k} \right] \quad \text{for } E > E_c$$

$$S = \frac{k}{e} \left[\left(\frac{E_F - E_v}{kT} \right)_0 + A_v - \frac{\delta_{VF}}{k} \right] \quad \text{for } E < E_v$$

$$A_c = \int_0^{\infty} \frac{E}{kT} \sigma(E) dE / \int_0^{\infty} \sigma(E) dE \quad E = E - E_c$$



$$E_c - E_F \left(\frac{E_c - E_F}{kT} \right)_0 - \frac{\delta_{CF}}{k} T$$

H. Fritzsche, Sol. State Commun.
9 (1971) 1813

Metallic conduction

$$f(1-f) = -kT df/dE$$

expanding $g(E)\mu(E)$ in a Taylor series

$$S = -\frac{\pi^2}{3} \frac{k}{e} kT \left[d \ln \sigma(E) / dE \right]_{E_F} \quad (\text{Mott})$$

(15)

Thermopower S

$$\Delta V = S \Delta T$$

$$S = \pi / T$$

Peltier coefficient π = energy transported by the current carriers per unit charge

Energy measured relative to E_F

$$\pi = - \frac{1}{e} \int_{-\infty}^{+\infty} (E - E_F) \frac{\sigma(E) dE}{\sigma}$$

$$S = - \frac{k}{e} \int_{-\infty}^{+\infty} \frac{E - E_F}{kT} \frac{\sigma(E) dE}{\sigma}$$

$$\sigma(E) = e g(E) \mu(E) f(E) [1 - f(E)]$$

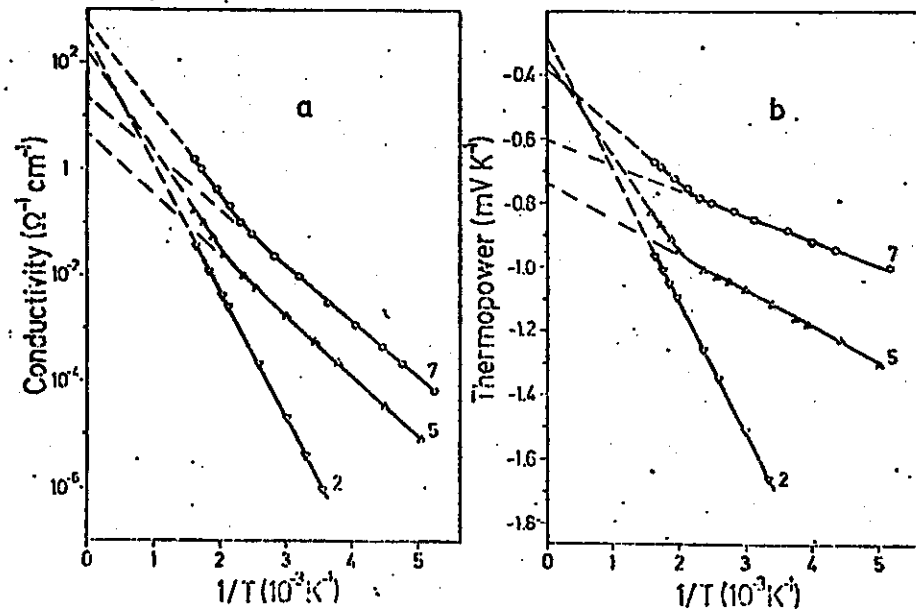
$$\sigma = \int_{-\infty}^{+\infty} \sigma(E) dE$$

$$\mu = \mu_0 e^{-W/kT}$$

Table 1

(16)

Sample	σ_0^M ($\Omega^{-1} \text{cm}^{-1}$)	B_σ (eV)	E_S (eV)	γ_a (meV/K)	γ_F (meV/K)
2	600	0.47	0.40	0.05	0.06
5 (a)	590	0.23	0.11	0.15	0.41
5 (b)	280	0.38	0.30	0.15	0.03
7 (a)	290	0.21	0.08	0.20	0.23
7 (b)	600	0.31	0.18	0.20	0.01



W. Beyer and R. Fischer Appl. Phys. Lett. 31 (1977) 12

Fig. 1

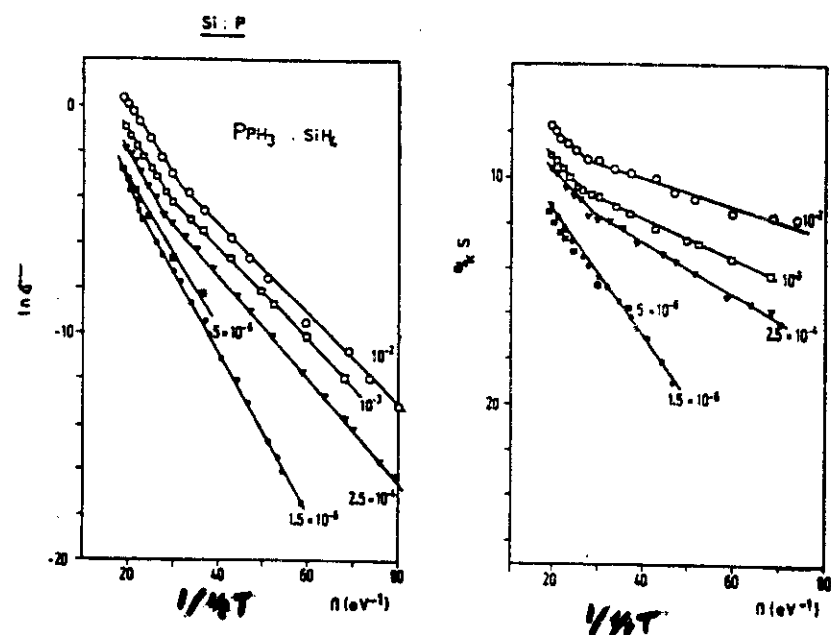


Fig. 1 Conductivity (a) and thermopower (b) of p-doped Si films doped with phosphorus vs β . The doping level is given in terms of the phosphine/silane pressure ratio.

W. Beyer and H. Overhof
Solid State Commun. 31 (1979) 1.

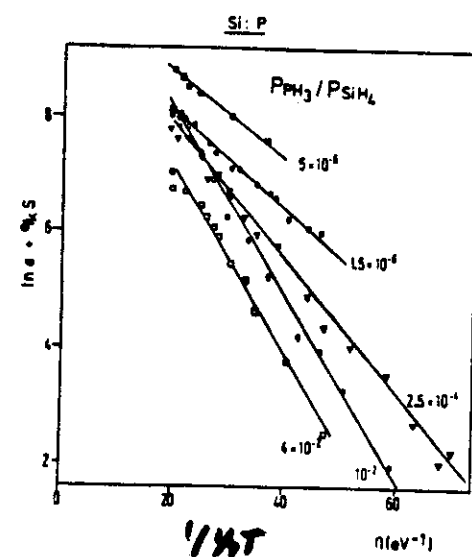


Fig. 2 $\ln \sigma + \frac{E_F}{kT}$ from the data of fig 1 vs β .

W. Beyer and H. Overhof
Solid State Commun. 31 (1979) 1.

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$$\sigma = \sigma_{\min} e^{-\left(\frac{E_c - E_F}{kT}\right)}$$

$$\frac{e}{k} S = -\frac{k}{q} \left(\frac{E_c - E_F}{kT} + A \right)$$

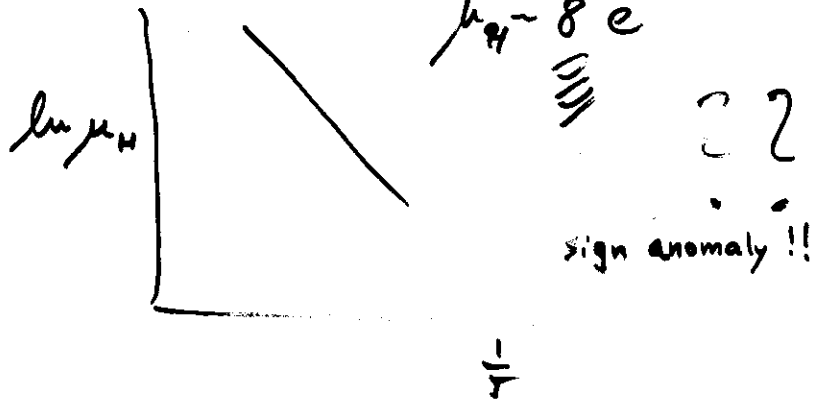
$$\ln \sigma = \ln \sigma_{\min} - \left(\frac{E_c - E_F}{kT} \right)$$

$$\ln \sigma - \frac{e}{k} S = \ln \sigma_{\min} + A$$

However, general observation:

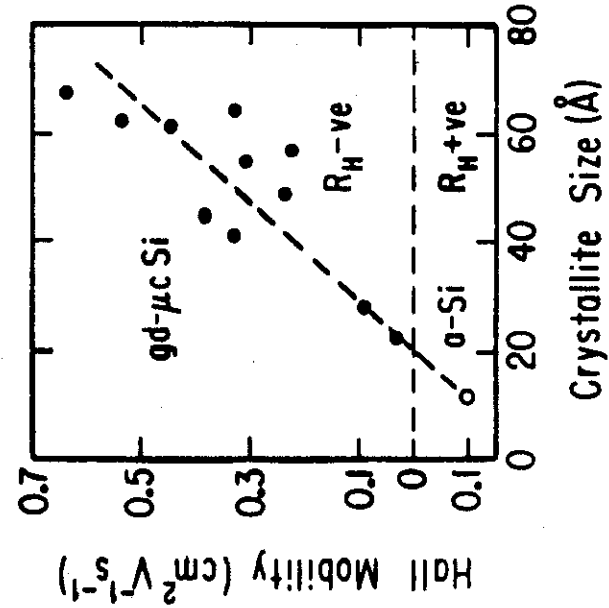
Hall effect $\ln \sigma - \frac{e}{k} S = \frac{E_F}{kT} + C$ with $E_F \approx 0.15 \text{ eV}$

J. Trasman, Appl. Phys. Lett 37 (1980) 742 - 0.15 eV



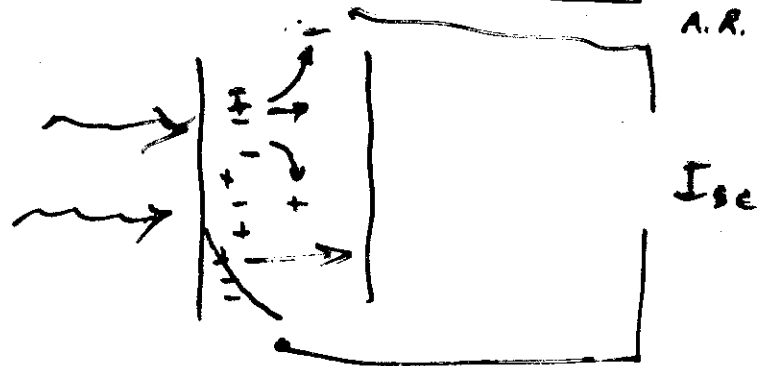
20

W.E. Spear, G. Willeke, P.G. LeComber
A.G. Fitzgerald Grenoble '81, J. de Physique
C4-10 (1981)



Photoelectromagnetic Effect

A.R. Moore



A.R. Moore, Appl. Phys. Lett. 37 (1980) 327.

$$I_{sc} = 10^{-8} B w q (\mu_e + \mu_h) I_0 L_p \frac{\alpha L_p}{1 + \alpha L_p}$$

$$L_p^2 = D_p \tau_p = \frac{kT}{q} \mu_p \tau_p$$

holes $\mu \tau = 3.2 \times 10^{-9} \text{ cm}^2/\text{V}$
 $\tau = 3.4 \times 10^{-7} \text{ sec}$

$$L_p = 0.09 \mu\text{m}$$

electrons $\mu \tau = 7.8 \times 10^{-8} \text{ cm}^2/\text{V}$
 $\tau = 1.7 \times 10^{-6} \text{ s}$

$$\mu = 0.05 \text{ cm}^2/\text{Vs}$$

Sign of effect normalSummary of 1st Lecture

$$1. \sigma = \sigma_0 \exp(-(E_c - E_F)_0 / kT) = \sigma_0 \exp(-E_\sigma / kT)$$

$$\sigma_0 = \sigma_{\min} \exp(\delta_{cf} / kT)$$

$$5 \leq \mu_0 \leq 20 \text{ cm}^2/\text{Vs}$$

$$10^3 \leq \sigma_0 \leq 10^4 \text{ ohm}^{-1}\text{cm}^{-1} \text{ for nearly all glasses}$$

• However: in a-Si:H

$$\sigma_0 \propto \exp(AE_\sigma) \quad \text{Mayer-Neldel Rule}$$

$$\text{with } A \approx 0.070 \text{ eV and } \sigma_0 > 10^6 \text{ ohm}^{-1}\text{cm}^{-1} \text{ for large } E_\sigma$$

$$2. S = -\frac{1}{2} \left(\frac{E_s}{kT} + A - \frac{\delta_{cf}}{kT} \right)$$

$$Q \approx \ln \sigma - \frac{q}{kT} S = \ln \sigma_{\min} + A - \frac{E_\sigma - E_s}{kT}$$

• However: $E_\sigma - E_s \neq 0$

$$0.1 \leq E_\sigma - E_s \leq 0.2 \text{ eV quite generally}$$

$$3. \text{ Hall mobility } \mu_H = R\sigma = \mu_0 \exp(-E_F / kT)$$

$$\text{in a-Si:H with } \mu_0 \sim 8 \text{ cm}^2/\text{Vs and } E_F \sim 0.15 \text{ eV}$$

• However: Hall effect has sign opposite to carrier

4. Photoelectromagnetic effect has correct sign and yields reasonable values for diffusion length.

Determination of Density of Gap States.

1. Field Effect

- α -Si:H W.E. Spear + P. LeComber, J. Non-Cryst. Sol. 8-10 (1972) 727
 A. Maden, P. LeComber, W.E. Spear, *ibid* 20 (1976) 239
 N.B. Goodman, H. Fritzsche + H. Ozaki, *ibid* 35-36 (1980) 579
 N.B. Goodman, H. Fritzsche, Phil. Mag. B42 (1980) 199

2. C-V

- α -Si:H M. Hirose, T. Suzuki, G.H. Pöhler, Appl. Phys. Lett. 34 (1979) 234
 T. Tiedje, C.R. Wronski, B. Abeles, J. Cebula, Solar Cells 2 (1980)

3. Deep Level Transient Spectroscopy (DLTS)

- α -Si:H D.V. Lang, J.D. Cohen, J.P. Harbison, Phys. Rev. B 25 (1982) 5205
 J.D. Cohen + D.V. Lang, *ibid.* 25 (1982) 5321

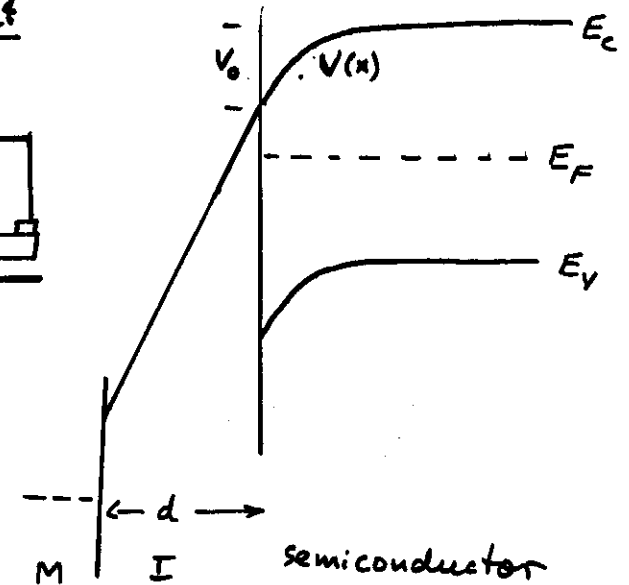
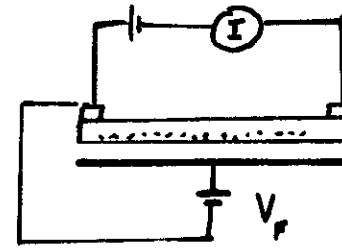
4. Xerographic Spectroscopy

- α -glass M. Abkowitz and R.C. Enck, Phys. Rev. B 25 (1982) 2867

5. Space-Charge-Limited Current Method

- W. den Boer, J. de Physique 42 (1981) C4-451

1. Field Effect



Poisson:
$$\frac{d^2 V(x)}{dx^2} = \frac{4\pi e}{\epsilon_s} \rho(x)$$

$$\rho(x) = \int_{-\infty}^{+\infty} dE g(E) [f(E - eV(x)) - f(E)]$$

$$\frac{G}{G_0} = \frac{\alpha}{\alpha+1} \frac{1}{t} \int_0^t dx \exp(eV(x)/kT) + \frac{1}{\alpha+1} \frac{1}{t} \int_0^t dx \exp(-eV(x)/kT)$$

$$G_0 = G_0(\text{electrons}) + G_0(\text{holes})$$

$$\alpha = G_0(\text{el}) / G_0(\text{holes})$$

$$\left. \vphantom{\frac{G}{G_0}} \right\} \text{ at } V_F = 0$$

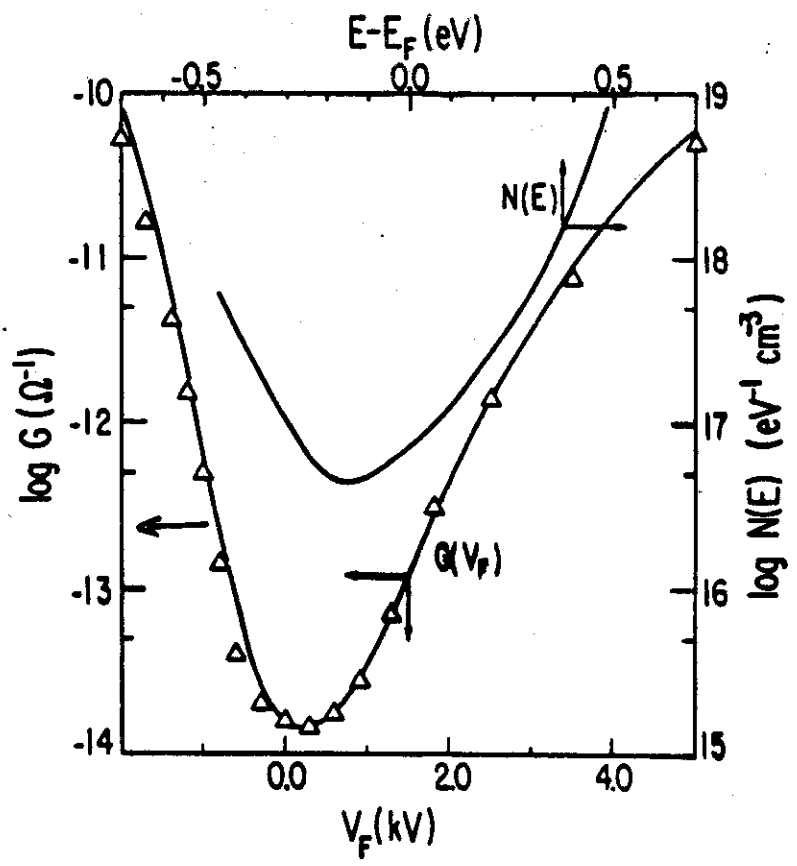
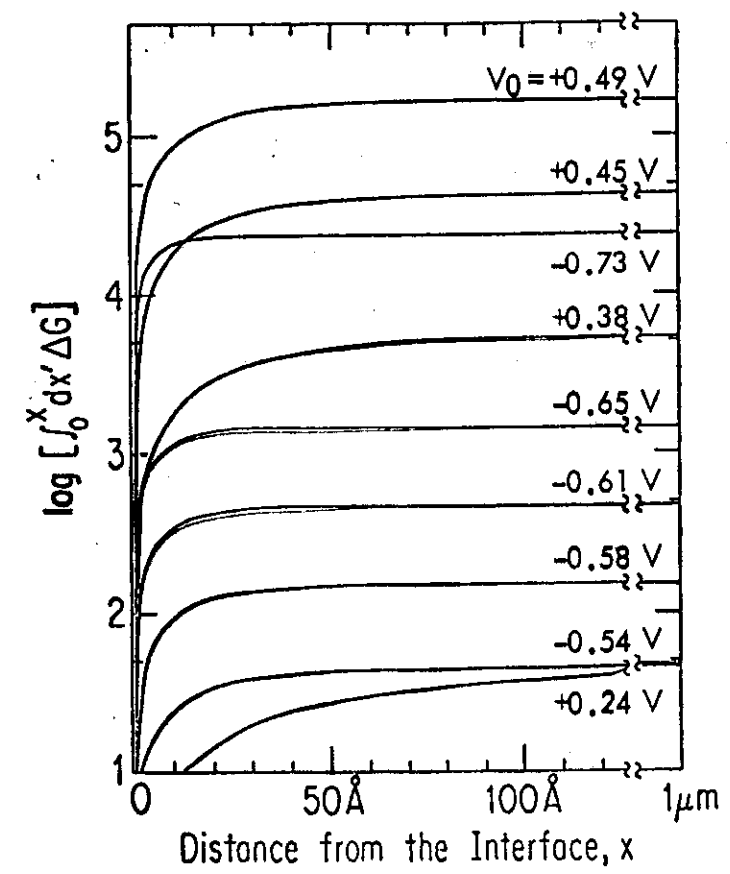
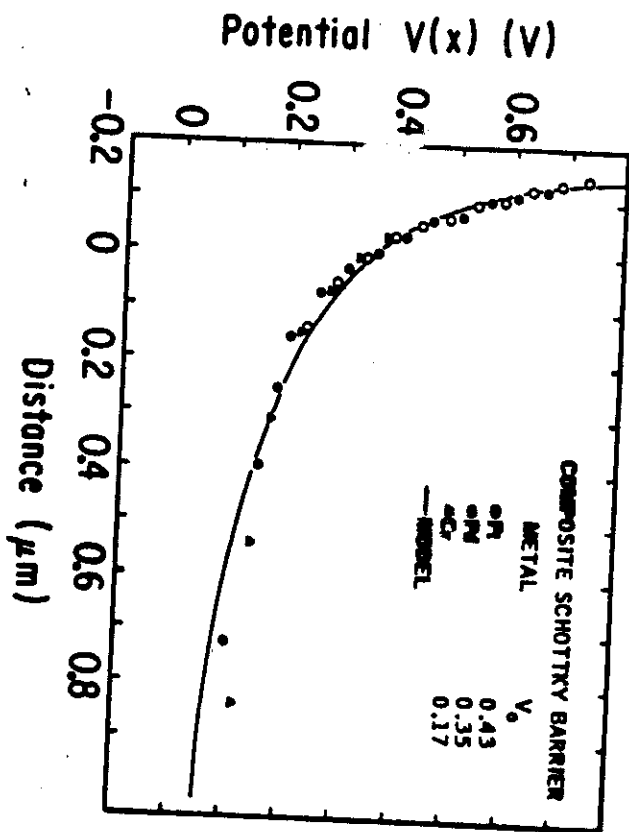


Fig. 15



(27)

(28)



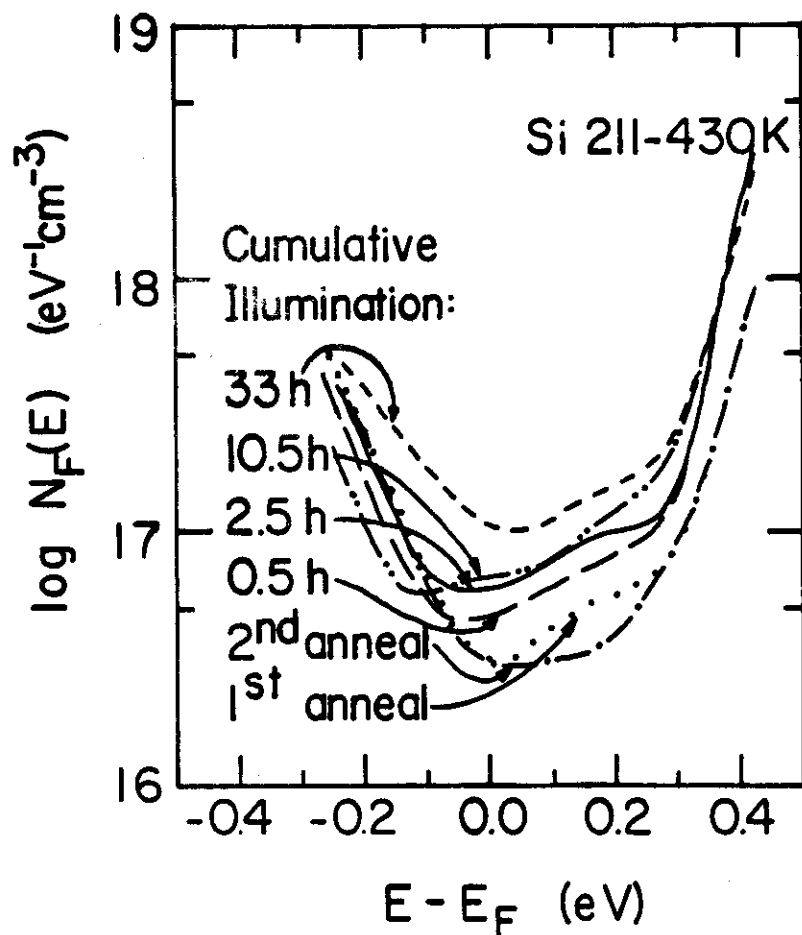
Tiedje, Wronski et al., Solar Cells 2 (1980)

Difficulties:

1. at large V_F current flows in 50 Å thick layer
2. $g(E)$ in first 50 Å layer ??
3. Localization condition in 2-dim. potential well, rigid shift $\sim V(x)$ of mobility edge ?
4. Is $\sigma_0 = \text{const}$ in $\sigma = \sigma_0 \exp[-(E_c(x) - E_F)/kT]$?
if $\sigma_0 = \sigma_{00} \exp A[E_c(x) - E_F]$ Meyer-Neldel Rule
then $g(E)$ will be lower by factor 5-10
5. No interface states ?

Success: Observation of photocreation of defects
of thermal annealing of defects
of thermal creation of defects.

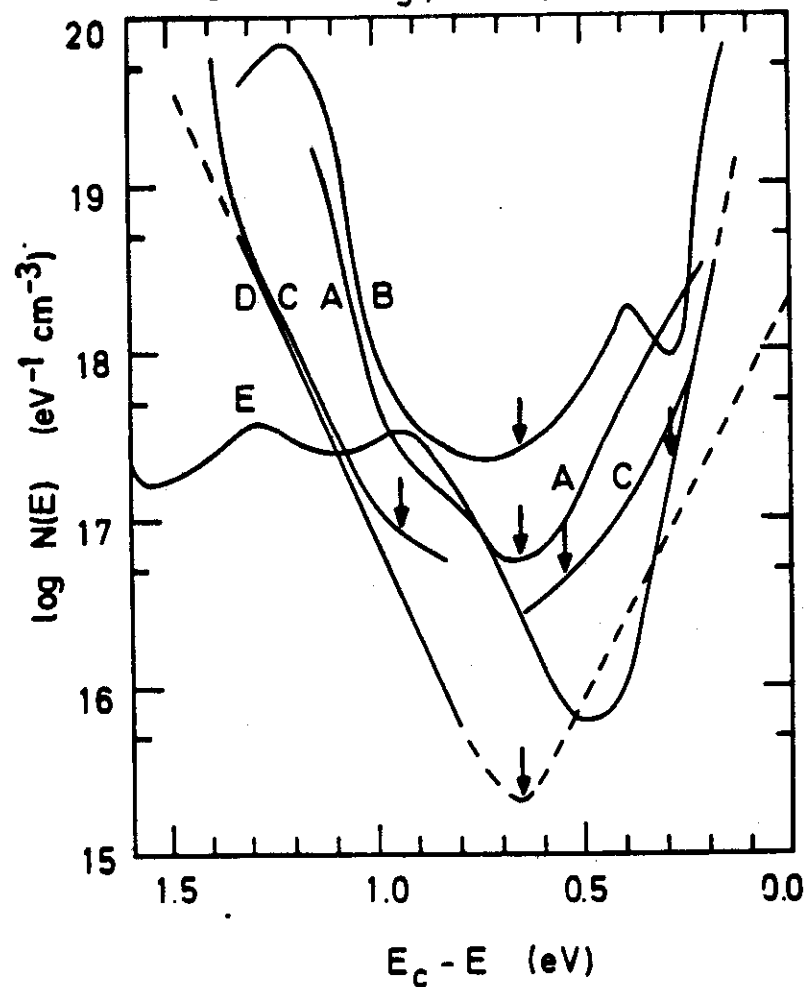
H. B. Goodman



(29)

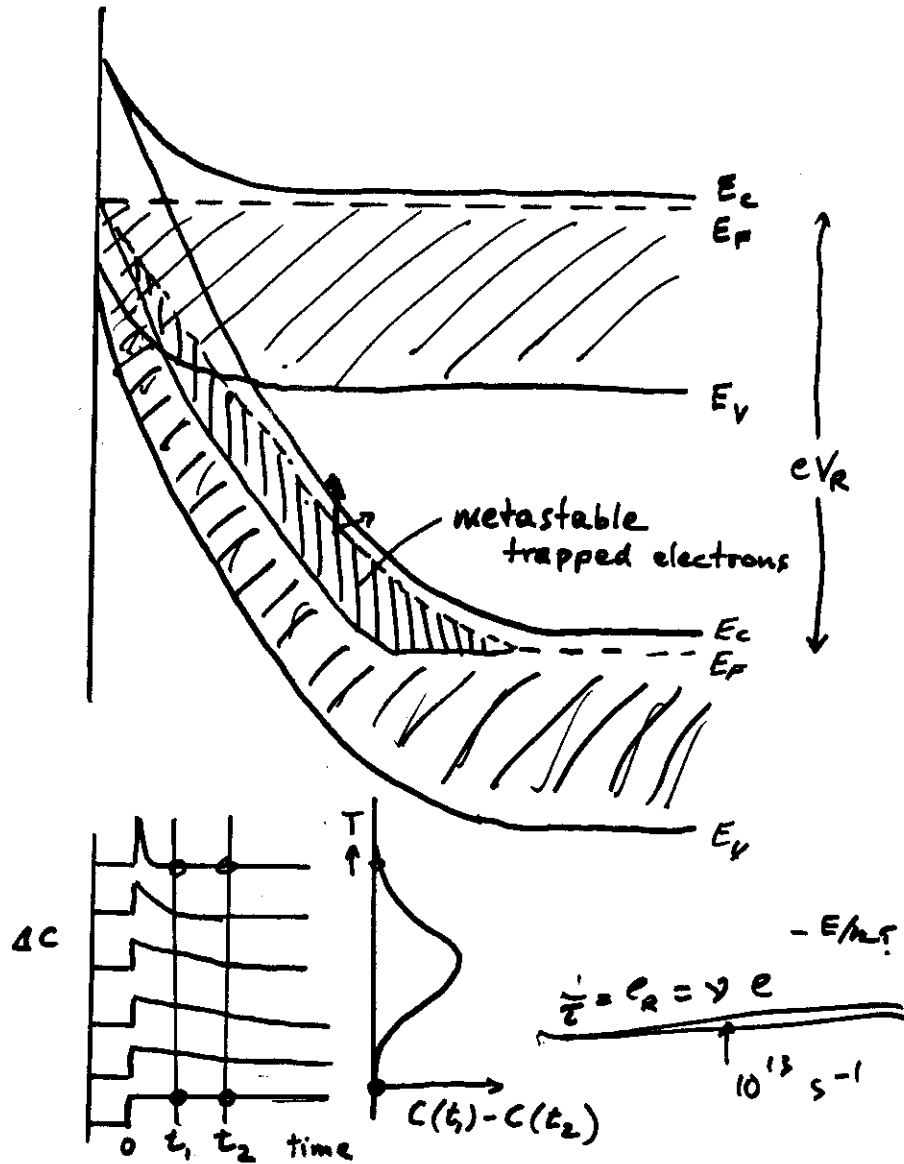
- A. Field Effect : Goodman + Fritzsche
- B. " " : Spear + LeComber
- C. C-V : Hirose, Suzuki + Döhler
- D. C-V : Tiedje, Wronski, Abeles, Gebula
- E. DLTS : Lang, Cohen, Harbison

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DLTS ΔC transient



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thermal emission rate $\frac{1}{\tau_e} = \gamma_0 \exp(-E/kT)$

$$\tau_{max} = \frac{t_2 - t_1}{\ln(t_2/t_1)} = \frac{1}{\text{DLTS rate window}}$$

$$\frac{\Delta C}{C} \approx 2 \frac{N_t}{N_s}$$

N_s = density of shallow levels which determine shape and size of depletion layer

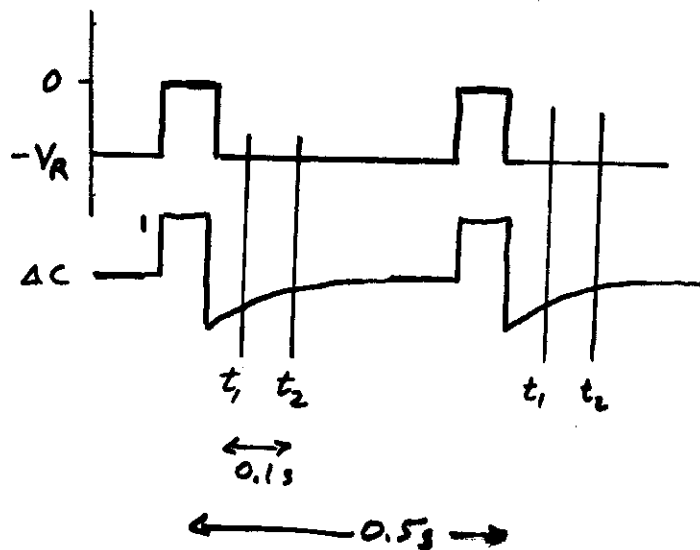
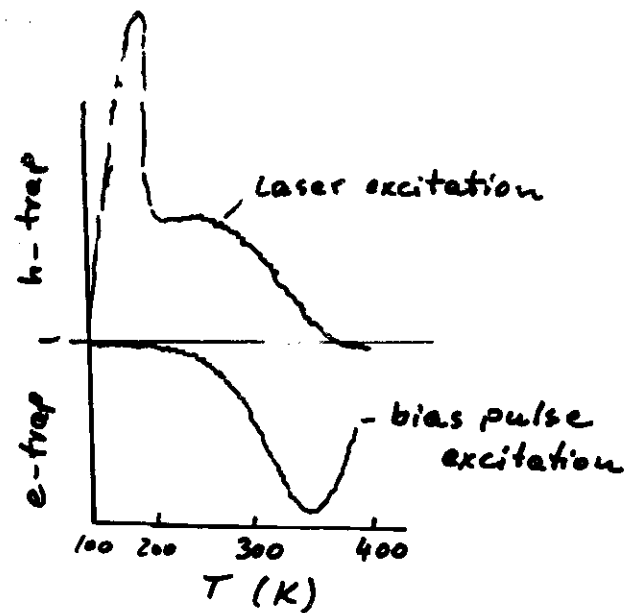
Difficulties

1. Assumption: attempt to escape frequency γ_0

$$\gamma_0 = \sigma_t v_{th} N_c = \text{same for all gap states}$$

2. thermal release independent of internal field $\sim 10^5 \text{ V/cm}$

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thermal emission density of states
for constant capture coefficient.

